METHODS FOR MAKING PLATED THROUGH HOLES USABLE AS INTERCONNECTION WIRE OR PROBE ATTACHMENTS

INVENTORS

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BACKGROUND

Technical Field

[0001] The present invention relates to methods for making plated through holes.

particularly, the present invention relates to methods for making plated through holes usable to

attach and support interconnection wires or probes.

Related Art

[0002] Plated through holes have been developed to connect electrical components on different

layers of multiple layer semiconductor structures, such as layers of a printed circuit board (PCB).

Plated through holes are further used to form interconnect elements enabling one PCB to be

connected to components on a separate PCB or other discrete electrical components.

[0003] With a single multilayered PCB, the plated through holes formed in the PCB during

manufacture serve to provide electrical coupling between circuits on the different layers.

Fabrication of a PCB typically includes drilling a hole through a substrate made up of the layers,

electrolytically plating the hole and conductive areas on the PCB layers with a metallic substance

such as copper to form the plated through hole. A first circuit pattern is then formed in the

conductive area on a first PCB layer and a second circuit pattern on a second PCB layer such that

the plated through hole electrically couples the first circuit pattern to the second circuit pattern.

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[0004] Plated through holes were developed for layered PCBs because it was generally found

impractical due to the labor and cost involved to form multiple connections by physically

inserting a conductive element (such as a wire) in a hole and then connecting the element to two

circuits by soldering or other means. As described above, the usual method of forming plated

through holes is to plate the circuits formed on the PCB layers and the through hole connections

simultaneously so that the through hole connection is made as an integral part of circuit elements

on different levels of the PCB without significant added labor or cost.

[0005] For two separate PCBs having electrical components to be connected after manufacture,

or one PCB to be connected to a separate discrete electrical component, an insertable conductive

element (such as a wire) forming a connector is still typically used. Such connectors can be

formed by inserting connector pins into plated through holes of separate PCBs and soldering

them in place. Such plated through holes provide connections between the pins and conductive

regions on the separate PCBs or discrete components. An example of a technique of

manufacturing PCBs with connector pins provided in plated through holes is described in U.S.

Patent No. 6,521,842, entitled "Hybrid Surface Mount And Pin Thru Hole Circuit Board."

[0006] Recently PCBs have been used to support multiple resilient wires or probes to form probe

cards used in temporarily connecting to electrical components, such as on semiconductor wafers

for testing. It would be desirable to provide a method for efficiently manufacturing such

multiple temporary connection elements for probe cards.

SUMMARY

[0007] In accordance with the present invention, methods are provided for making plated

through holes, or plated attachment wells to provide manufacturing flexibility. Methods are

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further described to enable the plated through holes or plated attachment wells to support wires

which may be used to form electrical connectors or test probes.

[0008] In a first embodiment, a method is provided for making plated through holes, which may

be curved. Initially wires made of an etchable or dissolvable material are bonded to a sacrificial

substrate. The wires are curved if curved plated through holes are desired. The wires are then

plated with a durable conductive material that does not dissolve under the same conditions as the

wire material. The plated wires are then encased in a dielectric material, such as epoxy or

ceramic, to form a substrate containing the coated wires, leaving a portion of the wires exposed

extending beyond the dielectric material layer. The substrate is then planed to expose the wire

material inside the plating. The wire material is then etched or dissolved leaving plated through

holes.

[0009] Plated through holes formed by the first embodiment can be used as interconnect

elements by inserting a rod into one end of the plated through holes, while forming solder bumps

on the other ends. Alternatively, interconnect wires can be inserted through curved plated

through holes, with the curved portion of the plated through holes providing friction to prevent

the interconnect wires from falling out. As another alternative, the probe wires can be inserted

through the plated through holes and soldered in to assure they cannot be easily removed,

particularly if the plated through holes are not curved.

[0010] In a second embodiment, a method is provided for making plated through holes extending

from a substrate, wherein a thin fiber wire is provided within each plated through hole. Initially

in the second embodiment, wires coated with a layer of dissolvable material are bonded to a

sacrificial substrate. A plating layer is applied over the dissolvable material. Next the plating is

partially ground down or polished to expose a portion of the dissolvable material coating the

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wires. The dissolvable material is then etched away or dissolved leaving plated through holes

formed by the plating material extending above a substrate with wires disposed inside.

[0011] In a third embodiment, a method is provided for forming plated attachment wells for

supporting connector wires or rods using photolithography techniques. For this method a layer

of masking material is initially deposited on a substrate and etched to form holes, which are

filled with a sacrificial fill material. The masking material is then removed, and the sacrificial

fill material plated with a conductive material. Grinding is performed to remove some plating to

a desired height above the substrate exposing the sacrificial fill material. The sacrificial fill

material is then etched away leaving plated attachment wells. Wires or rods may then be

inserted into the plated attachment wells and soldered in place.

[0012] The plated through holes formed, as described above, may be used to interconnect layers

of a single PCB. Resilient interconnect wires can be rigidly provided in the plated through holes

by solder or epoxy, or configured to be pluggable or unpluggable making spring contact with a

plated through hole or attachment well without requiring solder or epoxy for support. The

interconnect wires or probes can further be rigidly connected to electrical components on other

substrate layers (by solder or other means), or temporarily connectable resilient spring contacts

(essentially forming test probe cards). As one example, the resilient interconnect probes

provided in the plated through holes can be the probes described in U.S. Patent No. 5,994,152.

[0013] In a further embodiment plated twisted tube springs forming twisted plated through holes

are encased in a dielectric substrate to form an interconnect layer. Initially to form the substrate

with twisted tube springs, wires made of a dissolvable material are twisted to a desired pitch,

plated with an electrically conductive alloy and inserted into holes of a set of brass stencils. A

dielectric substrate material is then formed around the twisted wires with a portion of the wires

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extending beyond the dielectric, and the dissolvable wire material and brass stencils are etched

away leaving only the electrically conductive tubes encased in a dielectric substrate.

BRIEF DESCRIPTION OF THE DRAWINGS

[0014] Further details of the present invention are explained with the help of the attached

drawings in which:

[0015] Figs. 1A-1D show cross-sectional views of a substrate illustrating processing steps of a

first method of manufacturing plated through holes;

[0016] Fig. 2 illustrates interconnect elements which may be attached to the plated through holes

made using the process shown in Figs. 1A-1D to form a space transformer for a probe assembly;

[0017] Figs. 3A-3C show how an interconnect element is formed by a thin wire inserted into the

plated through holes made using the process shown by Figs. 1A-1D;

[0018] Figs. 4A-4D show cross-sectional views of a substrate illustrating processing steps of a

second method of manufacturing plated through holes with a thin wire inside;

[0019] Figs. 5A-5E show cross-sectional views of a substrate illustrating processing steps of a

third method of manufacturing plated attachment wells;

[0020] Figs. 6-7 illustrate attachment of interconnect probes in the plated attachment wells made

using the process shown in Figs. 5A-5E;

[0021] Figs. 8A-8B show an alternative configuration for manufacturing a plated attachment

well to support a probe without the need for soldering; and

[0022] Figs. 9A-9E show cross-sectional views illustrating processing steps for manufacturing

encased twisted tube springs that can be used as a layer for electrically interconnecting two other

substrate layers.

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DETAILED DESCRIPTION

[0023] Figs. 1A-1D show cross sectional views illustrating steps of a first method of making a

substrate with plated through holes, where the plated through holes may be curved. In a first step

shown in Fig. 1A, wires 2 are bonded to a first sacrificial substrate 4. The wires 2 may be

bonded using standard wire bonding techniques, such as soldering or thermosonic bonding. The

wires 2 are preferably made of a material that is readily etched or dissolved (e.g., copper, gold,

aluminum). The wires are curved if curved plated through holes are desired, or straight if

straight plated through holes are desired.

[0024] The first sacrificial substrate 4 can be formed using any number of desirable substrate

materials. Examples of suitable substrate materials include silicon, ceramic, Iron/Nickel alloys

(e.g., "alloy 42," "Kovar," "CuInvarCU"), etc. To facilitate eventual release of the structures to

be formed on the first sacrificial substrate 4, its surface can be coated with a release layer, which

may be a material that is readily etched away. Suitable release materials include copper, gold,

aluminum and titanium-tungsten, but are not limited by these examples. The surface of the first

sacrificial substrate 4 may also be coated with a material that facilitates bonding the wires 2 to its

surface. Such materials include, for example, gold, palladium or silver. The coating which

serves to facilitate bonding can likewise serve to form a redistribution layer, similar to copper on

a printed circuit board (PCB). With a redistribution layer exposed after the sacrificial substrate 4

has been etched away, components can be attached to the coating or solder bumps can be placed

in a fixed pattern. This gives the possibility of a second redistribution layer including: 1) where

coated wires or probes are attached to the coating to connect to the second layer, and 2) where

traces are deposited to connect to a second layer.

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[0025] As shown in Fig. 1B, the wires 2 are coated with a durable plating material 6 such as

rhodium or palladium. Traces can be used as a mask to etch the wire-coating layer to connect to

other components. Any deposition method may be used, including electroplate, chemical vapor

deposition, sputter deposition, electrolysis plating, electron beam deposition, or thermal

evaporation. If electroplating is used, it may be desirable first to short the wires 2 together. This

may be done in a variety of ways including (1) applying a layer of conductive material (a

shorting layer) to the surface of the first sacrificial substrate, if the sacrificial substrate is not

conductive in the first place, and then bonding the wires to the shorting layer, or (2) providing

connections from each wire through the first sacrificial substrate (e.g., through vias in the

substrate) to a shorting layer applied to the back side of the first sacrificial substrate 6. If the

second of these two methods is used, the plating material 6 will form only on the wires 2 but not

on the surface of the first sacrificial substrate 4.

[0026] The plating 6 shown in Fig. 1B assumes that a shorting layer was applied to both the

surface of the first sacrificial substrate and the wires bonded to the shorting layer. The plating

thus forms on the wires and over the entire surface of the first sacrificial substrate. As an

alternative, masking material can be placed over selected areas of the shorting layer, preventing

the plating from forming where the masking material is placed. The masking material can be

used to pattern traces, which are formed in combination with the plated wires to connect the

wires 2 to additional redistribution layers as described previously.

[0027] As will be seen, the wires 2 will be etched away, leaving a tube formed of the plating

material 6. Alternatively, the wires can be pulled out in a separate operation after the coating is

removed. To increase the inner diameter of this tube, one or more intermediate etchable layers,

may be formed on the wire prior to application of the final plating material that will form the

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tube. The intermediate etchable layers will then be etched away with the wires 2. Alternatively,

thicker wires can be used.

[0028] As shown in Fig. 1C, the plated wires are then encased in a final dielectric substrate

material 8. Examples of material usable for the substrate 8 include (1) an epoxy that sets into a

relatively hard, durable form, (2) a ceramic material like LTCC and HTCC, or (3) a glass

material, etc. The dielectric can have its surface metalized by applying a coating using a known

technique such as Chemical Vapor Deposition (CVD). The entire substrate can be electroplated

with for example with nickel or a nickel alloy. The bulk substrate can then be grounded and

used for impedance control.

[0029] Next, as shown in Fig. 1D, the first sacrificial substrate 4 is removed, and the top and

bottom of the resulting structure are planarized, such as by polishing, lapping, grinding etc.

Etching is then performed to remove the wires 2 leaving the plated material to form plated

through holes 10. Planarizing the top is done enough to remove a portion of the plating 6 to

expose the etchable wire material 2, so that the wire material 2 can be etched away. Planarizing

the bottom can be done to remove the portion of the plating material 6 originally on the surface

of substrate 4. Alternatively, rather than planarize the entire bottom surface, selected portions of

the plating 6 on the bottom surface of the substrate 4 may be etched so that the through holes are

not shorted together. Of course, if a masking material was applied to the structure shown in Fig.

1A between the wires 2 prior to plating, then the plating 6 shown in Fig. 1B would not have

formed where the masking material was disposed, and the wires (and resulting through holes

shown in Fig. 1D) would not be shorted together.

[0030] Fig. 2 shows a cross sectional view of the substrate 8 with plated through holes 10 formed

by the process of Figs. 1A-1D, illustrating examples of how interconnect elements, such as rods

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or probes, can be attached. As shown in Fig. 2, ends of interconnect elements in the form of

electrically conductive rods or probes 12 are inserted in and secured (e.g., by soldering) to the

plated through holes 10. Such insertable interconnect elements 12 may be rigidly attached to

another device, such as by soldering, to form a connector. The interconnect elements 12 can also

be resilient elements such as needle probes, cobra probes, or spring probes used to make

components of a probe card assembly for probing electronic devices, such as on semiconductor

wafers.

[0031] Non-limiting examples of spring probes which may be used for the interconnect element

12 are shown in U.S. Patent Nos. 5,994,152 and 6,255,126, U.S. Published Application No.

US2001/0044225 A1, and pending U.S. Patent Application No. 10/202,712, filed July 24, 2002,

all of which are incorporated herein by reference. Although the spring probes shown in some of

these illustrative examples, such as U.S. Patent 6,255,126, are not cylindrical to permit insertion

into the cylindrical openings in the plated through holes 10 shown in Fig. 2, plated through holes

with other shapes could be formed as would be understood by a person of skill in the art. For

example, the cylindrical wires 2 used in the steps of Figs. 1A-1E can be replaced by square rods

to enable the resulting plated through holes formed to match the square spring elements

described in U.S. Patent 6,255,126. Likewise wires with other geometrical shapes can be used to

create plated through holes of a similar shape depending upon the shape of the interconnect

element used.

[0032] Additional interconnect elements 14 may also be formed on the other side of the

substrate. In the example shown in Fig. 2, the interconnect elements 14 are solder balls

deposited over the plated through holes 10. Rod or probe interconnect elements 12 may be

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likewise inserted in place of the solder balls 14 to provide resilient contacts on both surfaces of

substrate 8.

[0033] With resilient probes 12 attached to one side of the substrate 8 and solder balls 14 on the

other (as shown in Fig. 2), a space transformer is formed which can be used in a probe card

assembly to directly connect to a semiconductor wafer or other device under test. The structure

of Fig. 2 can, thus, replace the space transformer 506 in Fig. 5 of U.S. Patent No. 5,974,662,

which is incorporated herein by reference. With resilient probes contacts attached to both sides

of a substrate (not shown in Fig. 2), an interposer, such as the interposer 504 of a probe card

assembly shown in Fig. 5 of U.S. Patent No. 5,974,662, can be formed. One or more structures

like the one shown in Fig. 2 may be secured to a larger substrate to build up a large array of

probes, such as the tile 600 attached to a space transformer 622 in Fig. 6A of U.S. Patent No.

5,806,181, incorporated herein by reference.

[0034] Figs. 3A-3C illustrate an additional interconnect element configuration which may be

used with the substrate 8 having plated through holes 10 formed by the process shown in Figs.

1A-1D. Figs. 3A-3C show how thin wires 16 are inserted into the plated through holes 10 of

substrate 8. In Fig. 3A, the thin wire 16 is inserted into one of the plated through holes 10 only

to a point where the plated through hole curves. The wire can be attached using solder similar to

the rods or probes of Fig. 2. With curved plated though holes, the thin wire 16 can be inserted

farther into the curved plated through hole 10, as shown in Fig. 3B, so soldering may not be

required because friction with the walls of the through holes 10 may be sufficient to hold the thin

wire 16 in place. If it is desirable to have thin wire probes extending from both sides of a

substrate, the thin wire 16 can be extended farther through the plated through hole 10, as shown

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Express Mail No: EL 977910501 US P189-US in Fig. 3C. Again, if the plated through hole is curved, friction will hold the thin wire, so

soldering may not be required.

[0035] The wires 16 may form buckling beam (or "cobra") type probes, with the substrate being

a probe head, space transformer, or tile for a probe card. For buckling beam probes, the wires 16

are made of a resilient material so that they bend when contact is made with another electrical

element, and then straighten out, or return to their original shape when disconnected. Because

the plated through holes 10 provide added current carrying capacity, the wires 16 may be thinner

than prior buckling beam probes. For example, such wires may have diameters less than .003

inches and in some embodiments .002 inches, .001 inches, or even smaller, while prior buckling

beam probes required diameters of at least .003 inches.

[0036] Figs. 4A-4D illustrate a method of making a plated through hole with a thin fiber inside.

As shown in Fig. 4A, a ball 20 is formed at the end of a wire 22 on a spool 21. The wire 22

comprises a thin fiber 23 (e.g., graphite) coated with a readily etched material layer 24 (e.g.,

copper, gold, aluminum). An electro-flame off tool 26, for example, may be used to cut the wire

22 to create the ball 20. As shown in Fig. 4B, the ball 20 is then bonded to a substrate 28 using

standard wire bonding techniques. Alternatively, the wires may be simply cut or sheared without

forming a ball, and the wired bonded directly to the substrate 28.

[0037] Wires 22 attached to the substrate 28 are next plated with a durable plating material 30

such as rhodium or palladium, as shown in Fig. 4C. Grinding or polishing is then performed to

remove a portion of the plating material 30 to expose a portion of the etchable material coating

layer 24. The etchable material layer 24 on the fiber 23 is then etched away, leaving the fiber 23

in a plated through hole tube formed by the durable plating material 30, as shown in Fig. 4D. All

of the etchable material coating 24 may be etched away, as shown in Fig. 4D, leaving the fiber

Attorney Docket No.: FACT-01001US0 TAW taw/fact/1001US0/1001US0.001 -11-

Express Mail No: EL 977910501 US P189-US 23 loose in the tube of plating material 30. Alternatively, a portion of the coating near the

bottom of the tube of plating material 30 may be left in place to better secure the fiber 23 inside

the tube 30.

[0038] The tube of plating material 30 can be bent or curved, causing an end of the wire 23 to

"pop" out of the end of the tube 30. The wire may be then more readily attached to form a

coaxial type connector with an air core. Alternatively, the fiber 23 can have multiple coatings,

only one of which will be readily etchable, so that after etching a wire will be provided within

multiple tubes.

[0039] As an alternative to using a wire 22 made up of a thin fiber 23 coated with a readily

etchable material layer 24, as described with respect to Figs. 4A-4D, the wires 22 used in the

process can be made entirely of an etchable material. As such, all of the wires 22 will be entirely

etched away in the process leaving only plated through hole tubes 30 standing on a substrate 28.

[0040] Figs. 5A-5E illustrate a method of making a plated attachment well. As shown in Fig.

5A, a substrate 40 is coated with a masking material 42 having openings. The openings are filled

with a sacrificial fill material 44, as shown in Fig. 5B. The substrate 40 may form the surface of

an electronic component, e.g. a space transformer, probe head, or tile for a probe card. As shown

in Fig. 5C, the masking material 42 is next removed, and the sacrificial fill material 44 is plated

with a durable plating material 46. Grinding stops 48 may optionally be attached to the substrate

40. As shown in Fig. 5D, a casting material 50 is applied. The casting material 50 is then

ground (or polished or lapped or otherwise ground down) to the grinding stops 48 (if attached),

as illustrated by the dashed line in Fig. 5D. After grinding the casting material 50, the grinding

stops 48 are removed and the sacrificial fill material 44 is etched away, leaving the plating

material forming attachment wells, as shown in Fig. 5E.

[0041] Rather than use grinding stops 48, a grinding machine may simply be configured to grind

to a specified height above the electronic component surface or to grind a specified distance into

the casting material. The grinding stops 48 may be any material that can be sensed by the

grinding machine, and the casting material 50 can be any material that will support the plated

sacrificial fill material during grinding and then can be readily removed (e.g., hard waxes,

polymers, etc.).

[0042] Figs. 6-7 illustrate exemplary uses of the substrate with attachment wells formed using

the method described with respect to Figs. 5A-5E. In Fig. 6, rods or probes 55 are inserted and

attached, e.g., by soldering to the attachment wells 46. Fig. 7 shows above surface wire type

spring probes 57 and 59, which can be inserted in the attachment wells. The spring probe 57 has

a slot 60 forming a compressible contacting surface when inserted within the well to securely

hold the probe 57 within the well. Even with the compression slot 60, soldering can be used to

assure the probe 57 remains engaged within the well. Probe 59 shows modification to the probe

57 to add laterally protruding bumps 61 as an alternative to assure the probe remains engaged

within the well. Other alternative wire-type probes may be formed by bonding wires inside the

wells. For example, the wire shown in Figs. 7A-7C of U.S. Patent No. 5,467,211 can be bonded

inside the well. Optionally, the wire can be coated as shown in Fig. 8 of U.S. Patent No.

5,467,211, incorporated herein by reference. When any of the wire-type probes are inserted, the

well can be filled with solder to increase the strength of its attachment if desired.

[0043] The sacrificial fill material used to form the attachment wells in Figs. 5A-5E can have a

shape other than cylindrical. The fill material can be square, rectangular, etc. As a further

alternative illustrated by the drawing in Fig. 8A, stacked structures of sacrificial fill material 62

can be formed by depositing and masking multiple layers 64 and 66. The structure of Fig. 8A

includes the rectangular layers 64 and 66, the smaller 64 being stacked on top the larger 66.

[0044] The sacrificial fill structure 62 of Fig. 8A is used to form an attachment well 68 as shown

in Fig. 8B, allowing a surface spring 69 to be attached without the need for soldering. The

spring probe 69 includes a compressible slot 70 and lateral extension bumps 72. The extension

bumps 72 extend into the large rectangular area, and engage the smaller rectangular area to

prevent the spring probe 69 from being easily removed after insertion in the attachment well 68.

[0045] Probes or wires can be inserted into the attachment wells or plated through holes either

one at a time, or together in a group fashion. For example, although only a single probe 69 is

shown in Fig. 8, multiple spring probes such as probe 69 can be held in a fixture which aligns the

probes for insertion into separate attachment wells, enabling the group of probes to be inserted

into attachment wells concurrently. Even without snapping the probes into attachment wells as

in Fig. 8, a fixture can hold groups of probes or wires in wells or holes while solder or epoxy is

applied to secure the probes or wires concurrently. With support provided by the attachment

wells or holes, groups of probes can potentially be transferred into the attachment wells or holes

concurrently without requiring a holding fixture for the probes. Probes or wires can be installed

in single or group fashion into the attachment wells or holes described herein, including the

attachment wells formed as shown in Figs. 5A-5E, or the plated through holes formed as shown

in Figs. 1A-1D. Wires or probes installed in a single or group fashion can include probes 12 of

Fig. 2, wire 16 of Figs. 3A-3C, probes 55 of Fig. 6, probes 57 and 59 of Fig. 7, or probe 69 of

Fig. 8B.

[0046] Figs. 9A-9E show cross-sectional views illustrating processing steps for manufacturing

encased twisted tube springs that can be used as a layer for electrically interconnecting two other

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substrate layers. In a first step shown in Fig. 9A, copper wires 74 with a square or rectangular

cross section are twisted to a specific twist pitch. The copper wires are then plated using a hard

and highly electrically conductive alloy such as rhodium. The coated wires are then cut to

length.

[0047] As shown in Fig. 9B, a set of brass stencils 75-76 are used to align the twisted wire rods

74. The base or bottom stencil 75 can be used as a key for the start of the twists if the wires are

not separately twisted before insertion into the stencils 75 and 76. A portion of the twisted rods

74 extend outside each stencil. After the twisted rods are inserted in the stencils 75-76, the gap

between the brass stencils is filled with epoxy 79 by molding a solid epoxy, or injecting the

epoxy in liquid form around the twisted wires, as shown in Fig. 9C.

[0048] As illustrated in Fig. 9D, the copper wire material and brass stencils 75 and 76 are next

dissolved leaving the hollow rhodium twisted tubes encased in epoxy. The rhodium tube springs

and epoxy layer now forms a layer 78 which can be used to interconnect other layers. With the

tubes aligned in a pattern by the brass stencils, the tubes of layer 78 can be aligned to match

probe locations on another substrate, as illustrated in Fig. 9D. Fig. 9E further shows the layer 78

with twisted tubes connected to mate with probes provided in attachment wells on a separate

layer 80 having attachment wells with probes as shown in Fig. 6. As shown in Fig. 9E, to

connect the layers 78 and 80, the probes on the layer 80 are inserted into the twisted tubes and

can be attached using solder joints 81.

[0049] The ability to rework a tile layer which supports spring probes (reworking meaning to

remove the tile and replace it with another tile) is very difficult to accomplish if soldering or

epoxy connects the tile layer and an interconnecting space transformer layer to make permanent

contacts between the layers. Probes are typically formed and attached by solder or epoxy to

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ceramic substrates to form tiles. The tiles are then attached to another multiplayer ceramic

substrate space transformer using a thin film copper polyamide epoxy layer.

[0050] Reworking to remove a tile from a space transformer is further made difficult if an

underfill material (such as a teflon or silicon gel) is used as a seal to fill gaps between a

connected tile and space transformer. The under fill material is used to absorb stress and prevent

cracking of the connecting thin film epoxy layer which can be under stress since during

fabrication the rate of thermal expansion of the ceramic and epoxy layers is quite different. The

difference in the coefficient of thermal expansion between the tile supporting the probes and the

multiplayer space transformer can cause a significant misalignment. The curved plated through

holes shown fabricated in Figs. 1A-1D can help alleviate the misalignment problem, along with

the underfill material. With different expansion rates between tile and space transformer layers,

the process of permanently joining the tile layer to the space transformer layer is challenging and

typically requires expensive x-ray procedures to inspect.

[0051] The difficulty with removing permanently connected tiles and space transformer layers is

similar to the difficulty in disconnecting individual spring probes from tiles, since the spring

probes must typically be directly attached with solder or an epoxy film to assure the probes

remain robust. One solution to making the probes more easily removable is to use the spring

contact probe and attachment well combination shown in Fig. 8B.

[0052] Although the present invention has been described above with particularity, this was

merely to teach one of ordinary skill in the art how to make and use the invention. Many

additional modifications will fall within the scope of the invention, as that scope is defined by

the following claims.

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